Attorney Docket No.: AM-6180 U.S. Express Mail No.: ER 885314622 US

## IN THE CLAIMS:

Please cancel Claims 1 - 21, 26, and 37 without prejudice. Please amend Claims 22, 27, 29, 33, 39, and 40 as follows:

1 - 21 (Cancelled)

- 22. (Currently Amended) A component for use within a semiconductor processing chamber, wherein said component has at least one ceramic surface which has <u>patterned</u> mechanical interlocks formed therein, wherein said <u>patterned</u> mechanical interlocks are undercut into said at least one ceramic surface using a process selected from the group consisting of pattern etching said ceramic surface through a mask using a chemical etchant, patterning etching said ceramic using a thermal etching process, and pattern etching said ceramic using a laser micromachining process which employs a laser system which includes optics for producing a patterned beam, and wherein a sacrificial coating which can be removed essentially without harming said ceramic surface has been applied over said ceramic surface containing said patterned mechanical interlocks.
- 23. (Original) The component of Claim 22, wherein said ceramic is selected from the group consisting of alumina, quartz, aluminum nitride, silicon carbide, silicon nitride, boron carbide, and combinations thereof.
- 24. (Cancelled)
- 25. (Cancelled)
- 26. (Cancelled)

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27. (Currently Amended) The component of Claim <del>26</del> <u>22</u>, wherein said sacrificial material is aluminum.

- 28. (Original) The component of Claim 27, wherein said aluminum layer has a thickness within the range of about 76 μm to about 1.5 mm.
- 29. (Currently Amended) The component of Claim 26-22, wherein said component includes a bond coat layer between said ceramic surface and said sacrificial material layer.
- 30. (Original) The component of Claim 29, wherein said bond coat layer comprises a material having a coefficient of thermal expansion which is no more than about 20% higher or lower than the coefficient of thermal expansion of said ceramic.
- 31. (Original) The component of Claim 29, wherein said ceramic comprises alumina, and said bond coat layer comprises a material selected from the group consisting of tantalum, rhenium, molybdenum, chromium, titanium, platinum, nickel, manganese, and combinations thereof.
- 32. (Original) The component of Claim 31, wherein said bond coat layer comprises tantalum, and said tantalum layer has a thickness within the range of about 7.6  $\mu$ m to about 38  $\mu$ m.
- 33. (Currently Amended) A deposition ring for use within a physical vapor deposition chamber, wherein said deposition ring has at least one ceramic surface which has <u>patterned</u> mechanical interlocks formed therein, wherein said <u>patterned</u> mechanical interlocks are undercut into said at least one ceramic surface using a process selected from the group consisting of pattern etching said ceramic surface through a mask using a chemical etchant, patterning etching

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said ceramic using a thermal etching process, and pattern etching said ceramic using a laser micromachining process which employs a laser system which includes optics for producing a patterned beam, and wherein a sacrificial coating which can be removed essentially without harming said ceramic surface has been applied over said ceramic surface containing said patterned mechanical interlocks.

- 34. (Original) The deposition ring of Claim 33, wherein said ceramic is selected from the group consisting of alumina, quartz, aluminum nitride, silicon carbide, silicon nitride, boron carbide, and combinations thereof.
- 35. (Cancelled)
- 36. (Cancelled)
- 37. (Cancelled)
- 38. (Currently Amended) The deposition ring of Claim 37 33, wherein said sacrificial material is aluminum.
- 39. (Original) The deposition ring of Claim 38, wherein said aluminum layer has a thickness within the range of about 76 μm to about 1.5 mm.
- 40. (Currently Amended) The deposition ring of Claim 37 33, wherein said deposition ring further includes a bond coat layer between said ceramic surface and said sacrificial material layer.

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41. (Original) The deposition ring of Claim 40, wherein said bond coat layer comprises a material having a coefficient of thermal expansion which is no more than about 20% higher or lower than the coefficient of thermal expansion of said ceramic.

- 42. (Original) The deposition ring of Claim 40, wherein said ceramic comprises alumina, and said bond coat layer comprises a material selected from the group consisting of tantalum, rhenium, molybdenum, chromium, titanium, platinum, nickel, manganese, and combinations thereof.
- 43. (Original) The deposition ring of Claim 42, wherein said bond coat layer comprises tantalum, and said tantalum layer has a thickness within the range of 7.6 μm to about 38 μm.

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